

# The measurement of the SiPM photon detection efficiency at ITC-irst

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# Outline

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- Photon Detection Efficiency (PDE) of the SiPM
- Experimental methods used for the PDE measurement
- PDE of the first SiPM prototypes developed at ITC-irst
- Summary and outlook

# Photon detection efficiency of the SiPM

## ➤ Traditional PDE:

$$\eta = \frac{\text{nr. of output pulses recorded}}{\text{nr. of photons emitted by light source}}$$

## ➤ PDE of the SiPM:

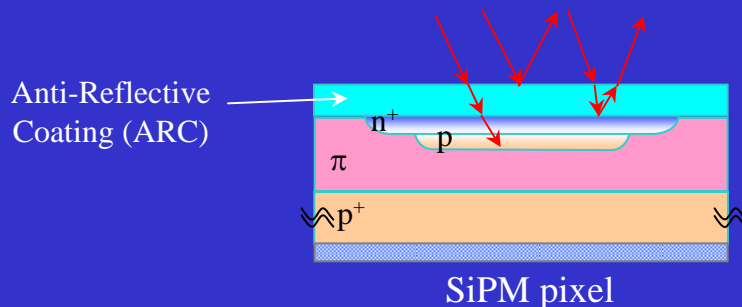
$$\eta_{SiPM} = QE \times P_{triggering} \times \varepsilon_{geom}$$

## 1. QE – the quantum efficiency

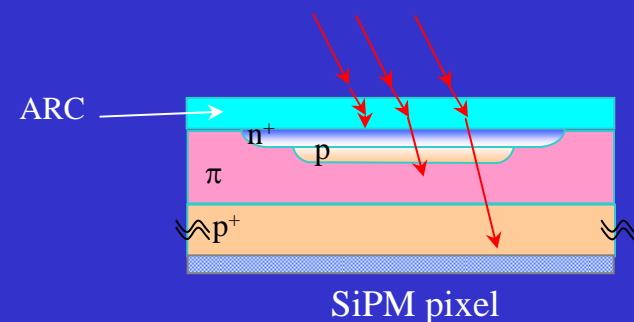
- probability that a photon generate an e/h pair in the active region of the device (e.g. n<sup>+</sup>/p junction of a pixel) - wavelength dependent

### a) transmission efficiency through ARC

(ARC = stack of dielectric layers with appropriate thickness and refraction index)



### b) internal quantum efficiency



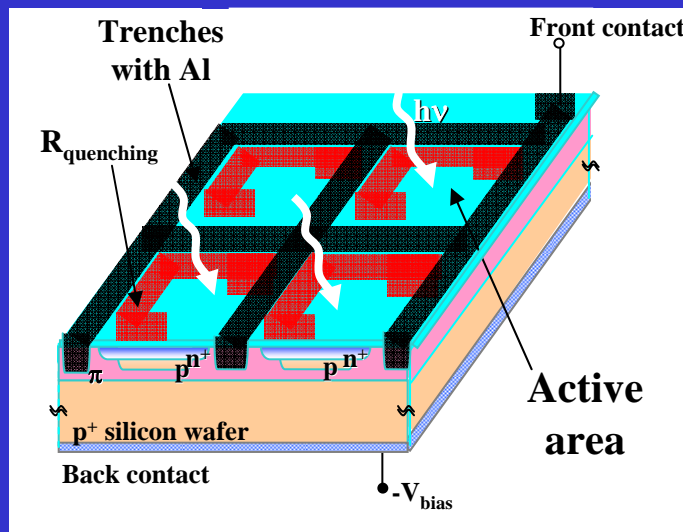
# Photon detection efficiency of the SiPM (cont)

## 2. $P_{\text{triggering}}$ – the triggering probability ( $P_t = P_e + P_h - P_e * P_h$ )

- probability that a carrier (e or h) traversing the high field region triggers an avalanche
- $P_e$  &  $P_h$  are linked to the impact ionization rates of the electrons and holes
  - electrons have higher ionization rates than holes
  - both electrons and holes ionization rates increase with the electric field (e.g. overvoltage)

## 3. $\epsilon_{\text{geom}}$ – the geometrical efficiency (active area / total area)

### SiPM



(design not in scale)

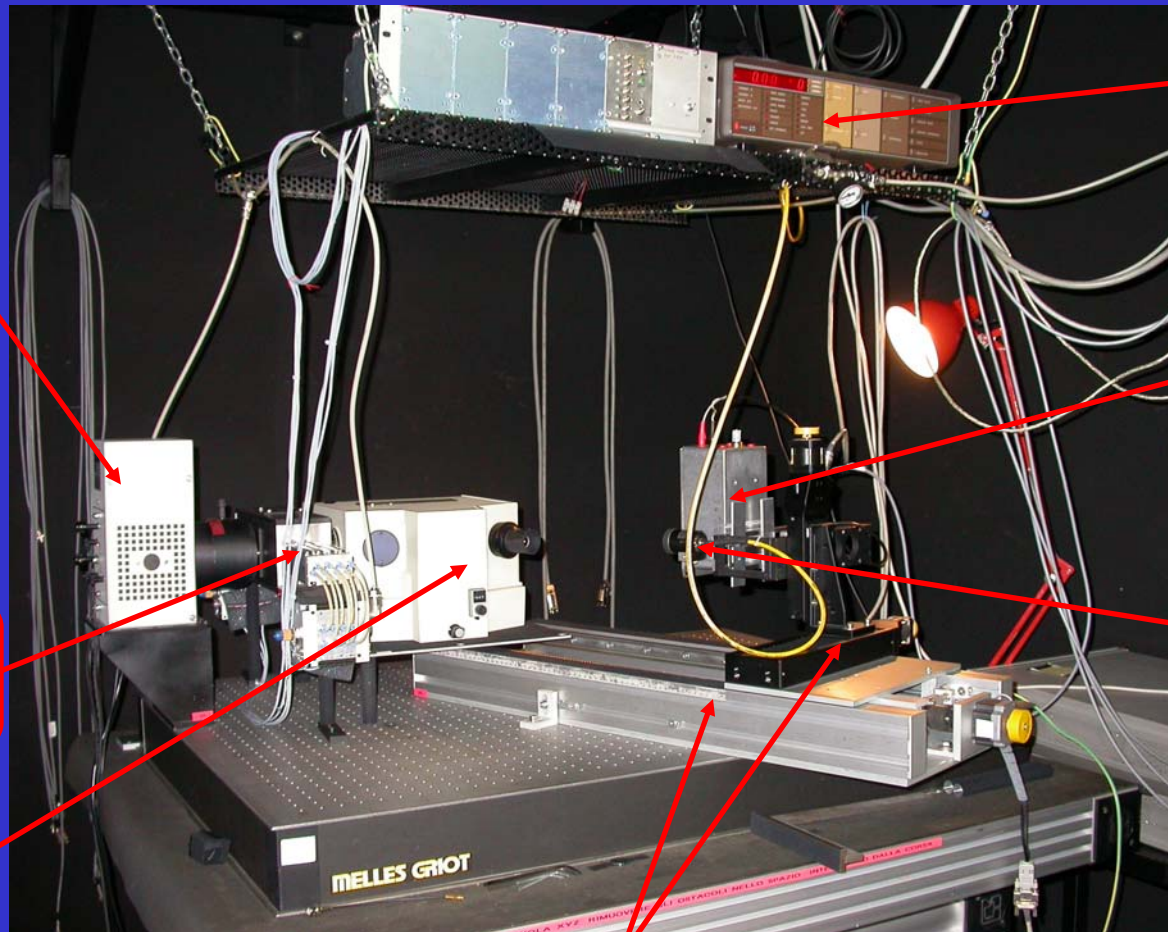
### ➤ Total area includes dead regions given by:

- quenching resistors
- trenches
- metal layers

### ➤ Active area:

- ~ 15- 30% of total area depending of the layout design

# The experimental set-up



Optometer

Halogen white lamp  
(OSRAM)

SiPM +  
preamplifier

Neutral filters  
(filter transmittance 10%)

Photodiode  
(UDT 221)

Monochromator  
(Jobin Yvon HR250)

Stage with 3D micrometric movement (50 $\mu$ m precision)

# The methods for the PDE measurement

$$\eta_{SiPM} = \frac{N_{\text{photons recorded by the SiPM}}}{N_{\text{incident photons on the SiPM surface}}}$$

$N_{\text{incident photons on the SiPM surface}}$

reference calibrated detector  
(photodiode)

$$N_{\text{inc. ph./s/mm}^2} = \Phi_{(W / \text{mm}^2)} \cdot \frac{\lambda}{hc}$$

$N_{\text{photons recorded by the SiPM}}$

DC method

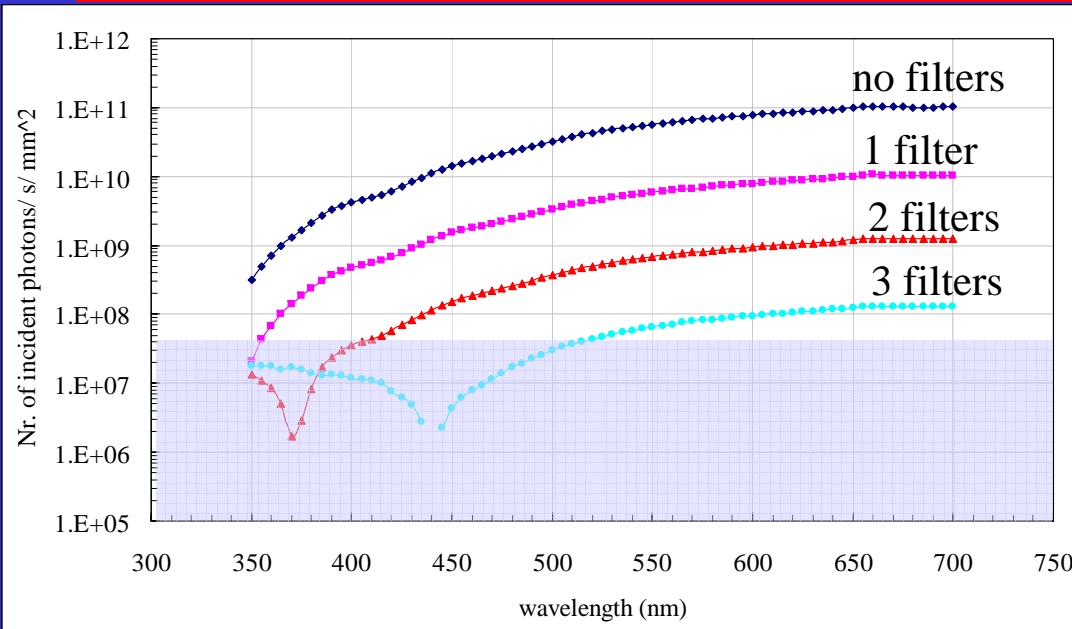
$$N_{\text{rec. ph./s/mm}^2} = \frac{I_{\text{light}} - I_{\text{dark}}}{G_{SiPM} \cdot q}$$

Pulses counting method

$$N_{\text{rec. ph./s/mm}^2} = (\text{light counts/s}) - (\text{dark counts/s})$$

(for low optical power densities)

# Set-up calibration



$$N_{inc. ph./s/mm^2} = \Phi_{(W/mm^2)} \cdot \frac{\lambda}{hc}$$

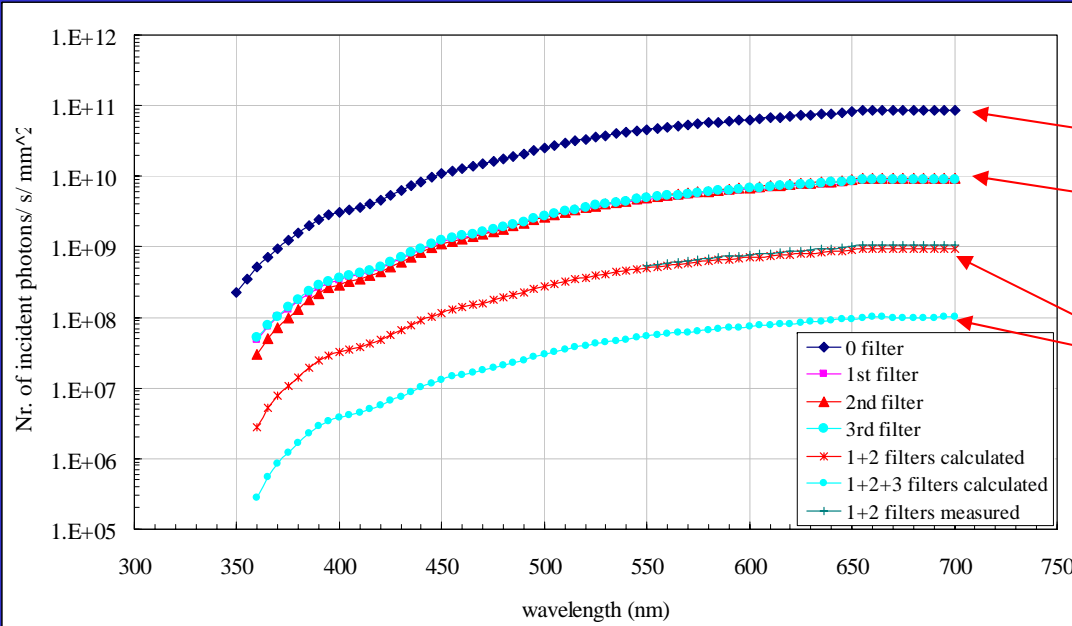
$$\Phi_{(W/mm^2)} = \frac{1}{A_{phot}(mm^2)} \cdot \frac{I_{phot}(A)}{R_{phot}(A/W)}$$

➤ Photodiode sensibility:

- ~ 4 x 10<sup>7</sup> photons/s/mm<sup>2</sup>

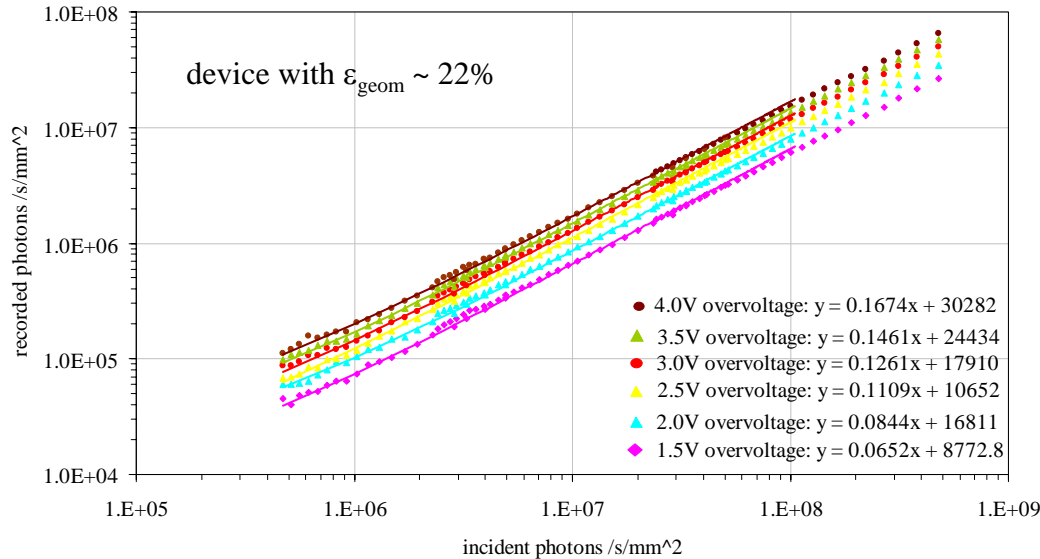
➤ Calibration method:

- light beam without any filter
- each filter separately
- each filter factor is calculated at all wavelengths
- if 2 or 3 filters are inserted simultaneously, the optical power density is calculated based on each filter factor determined previously



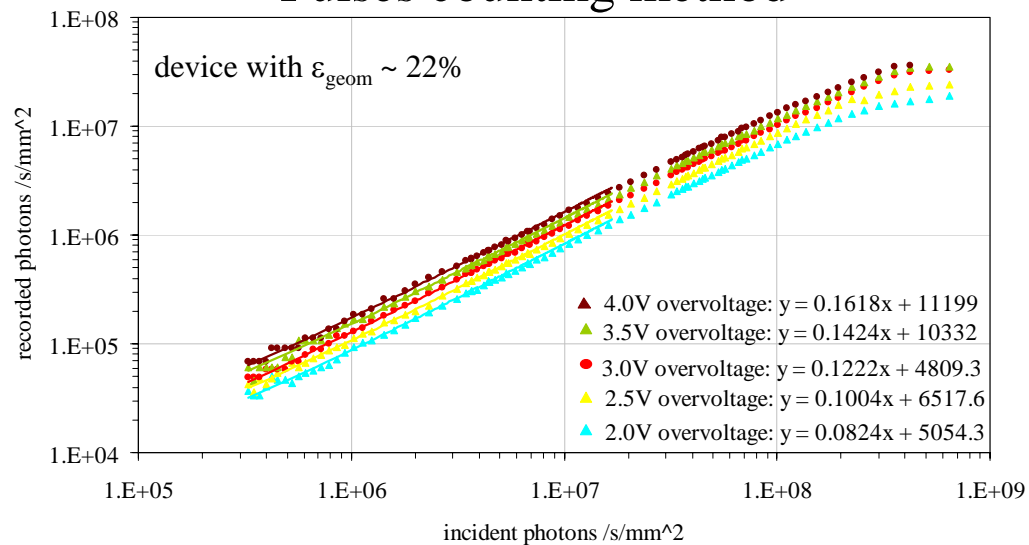
# PDE @ 550nm – DC & pulses counting methods (1)

## DC method



$$N_{\text{rec. ph./s/mm}^2} = \frac{I_{\text{light}} - I_{\text{dark}}}{G_{\text{SiPM}} \cdot q}$$

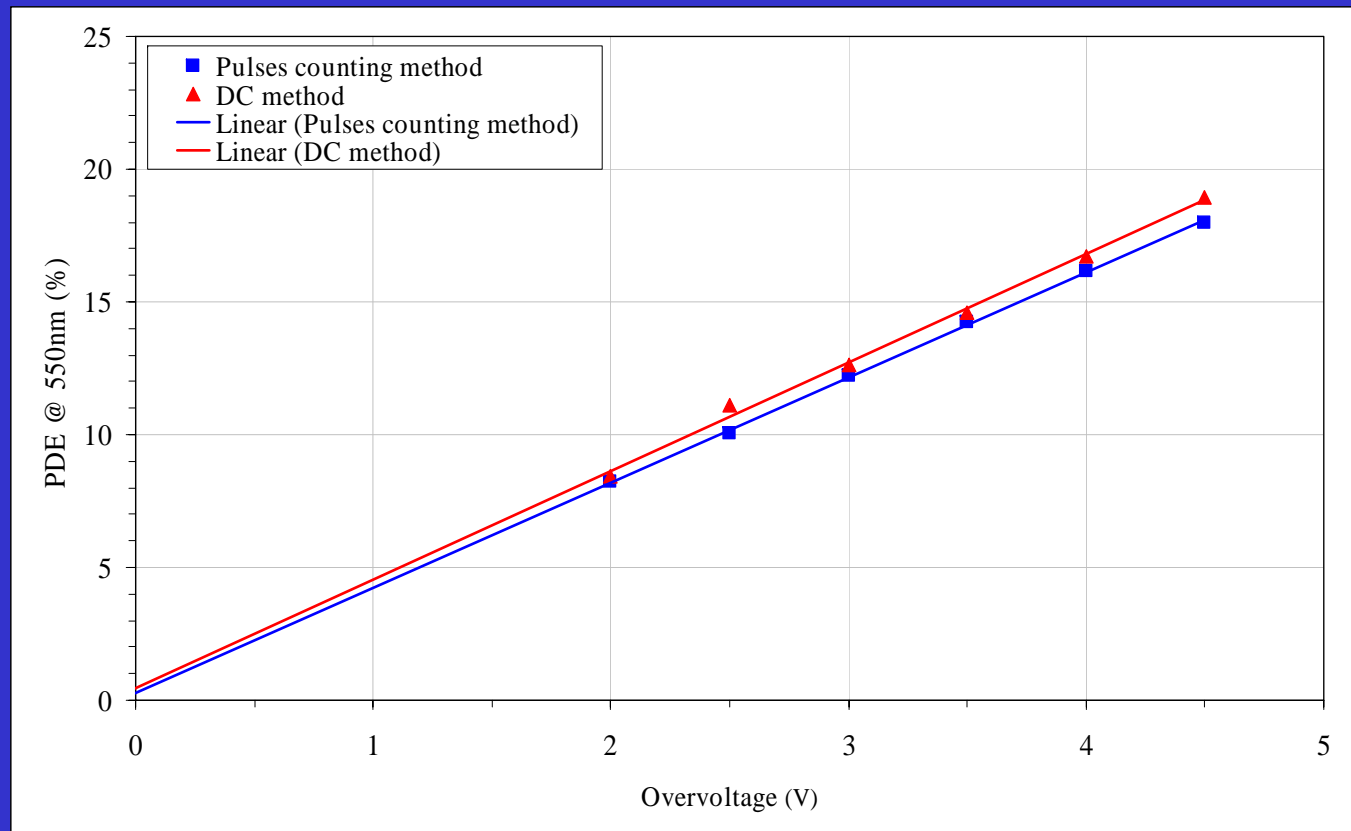
## Pulses counting method



$$N_{\text{rec. ph./s/mm}^2} = (\text{light counts/s}) - (\text{dark counts/s})$$

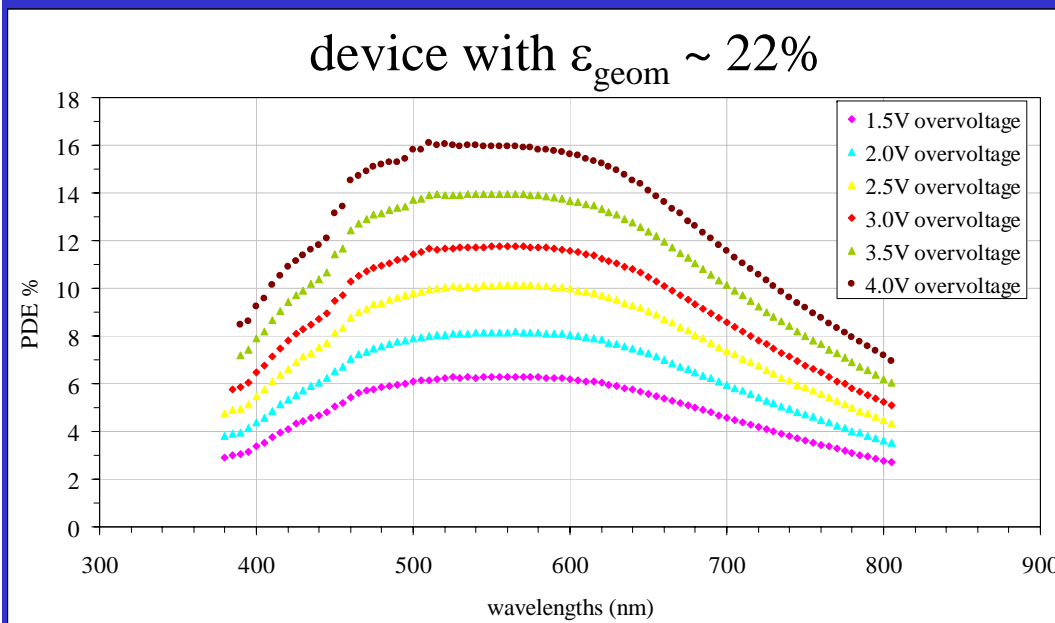
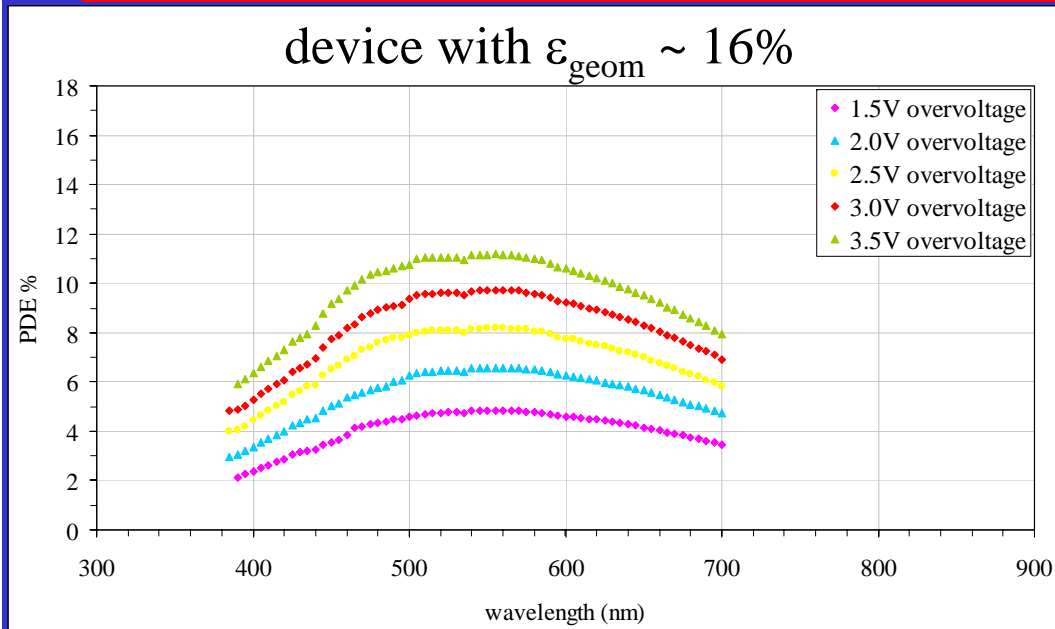


# PDE @ 550nm – DC & pulses counting methods (2)



- Very good agreement in between the DC and counting pulses methods
- PDE increases linearly with the overvoltage at least up to 5V overvoltage

# Photon detection efficiency – DC method



➤ Maximum PDE in the range

500 ÷ 600 nm

- ~ 16% @ 4V overvoltage for a SiPM of  $\epsilon_{\text{geom}} \sim 22\%$

➤ For low  $\lambda$

- the PDE is reduced by the  $P_{\text{triggering}}$  (only holes trigger the avalanche)

➤ For high  $\lambda$

- the PDE is reduced by the QE (QE was optimized for low  $\lambda$ )

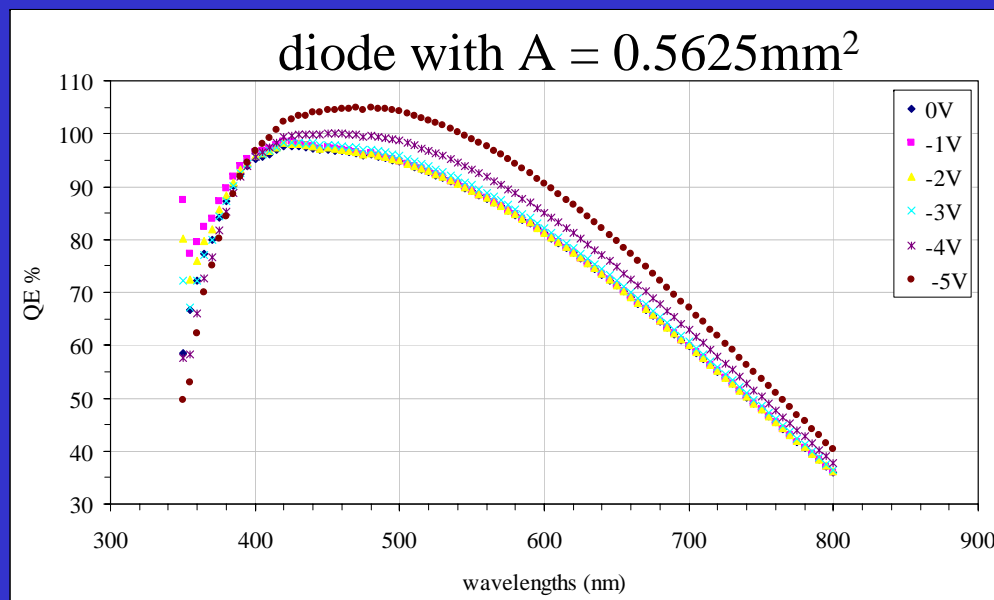
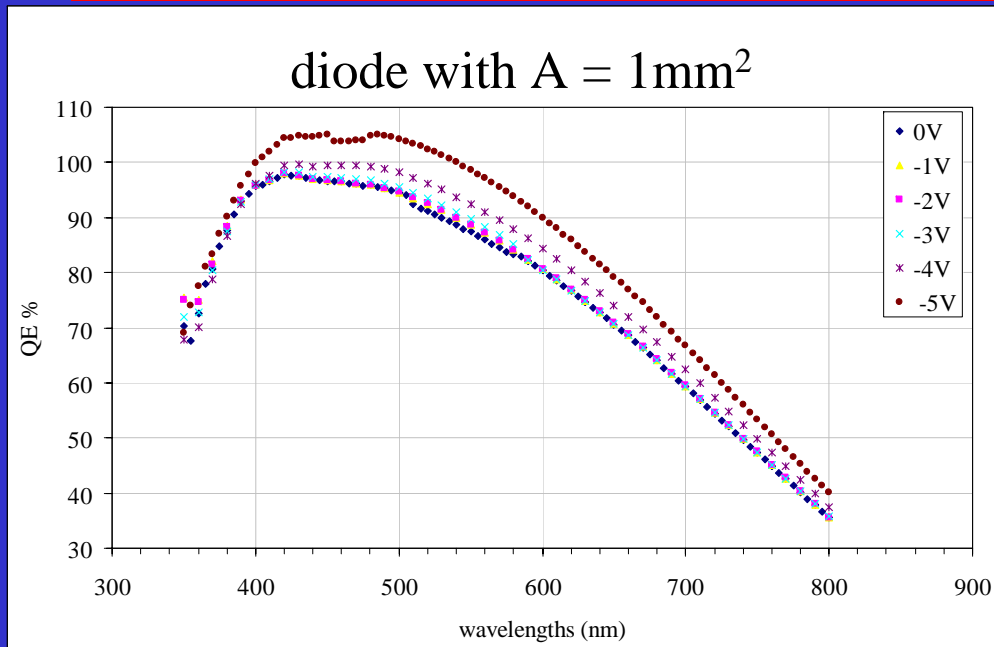
# Quantum efficiency

## ➤ Diode:

- Test structure with the same (n<sup>+</sup>/p junction + ARC) as each SiPM pixel
- Works as a photodiode at low reversed bias (0V, 1V or 2V)
- Allows the measurement of the QE (transmission through ARC & internal quantum efficiency)

## ➤ The impact ionization effect already visible at 3-4V

## ➤ QE > 95% in the blue region (optimized for $\lambda \sim 420\text{nm}$ )



# Triggering probability

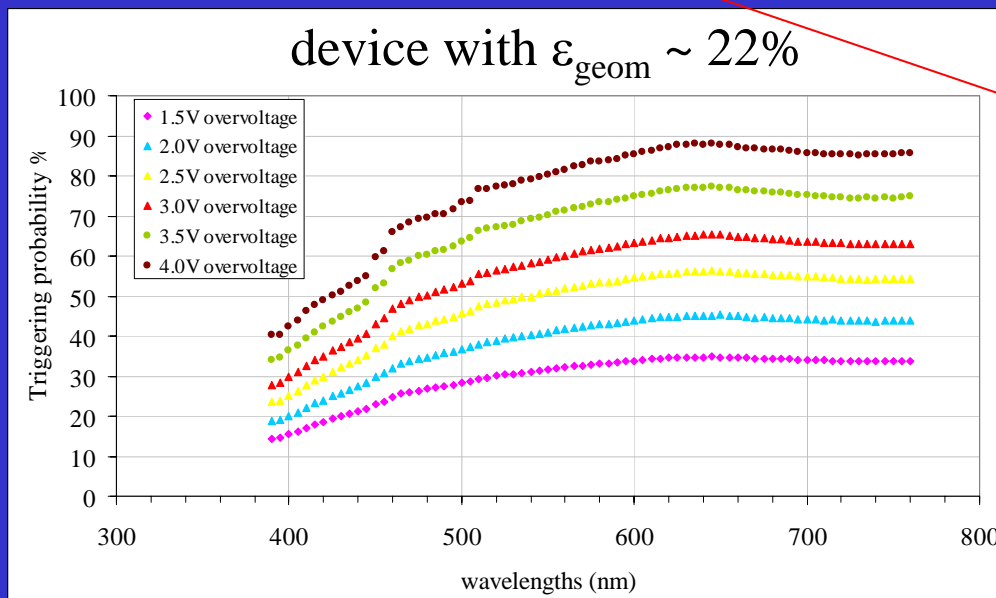
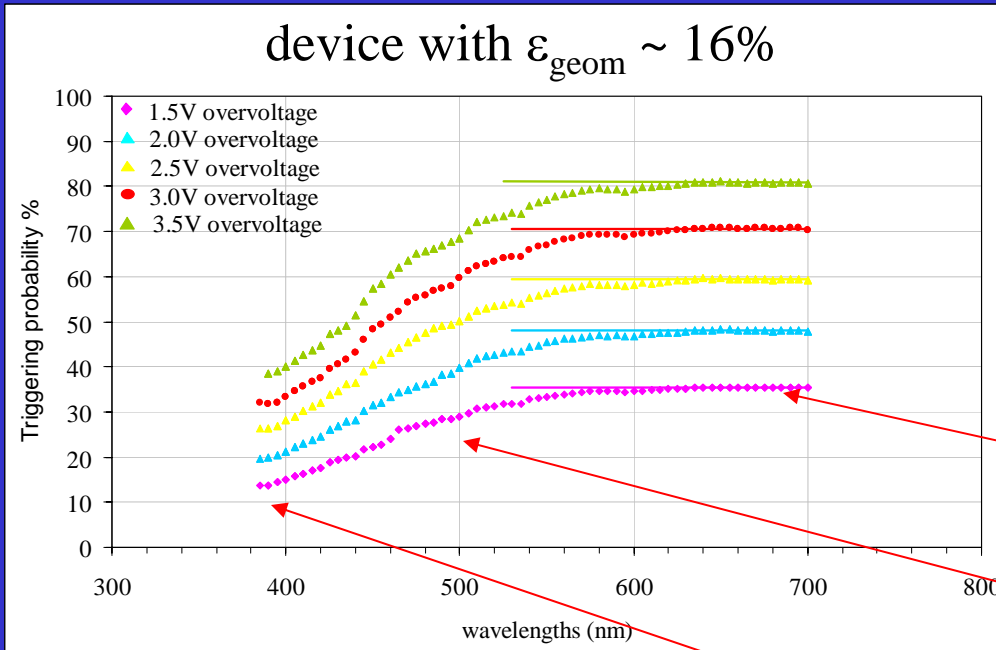
➤ Calculated from:

$$\eta_{SiPM} = QE \times P_{triggering} \times \epsilon_{geom}$$

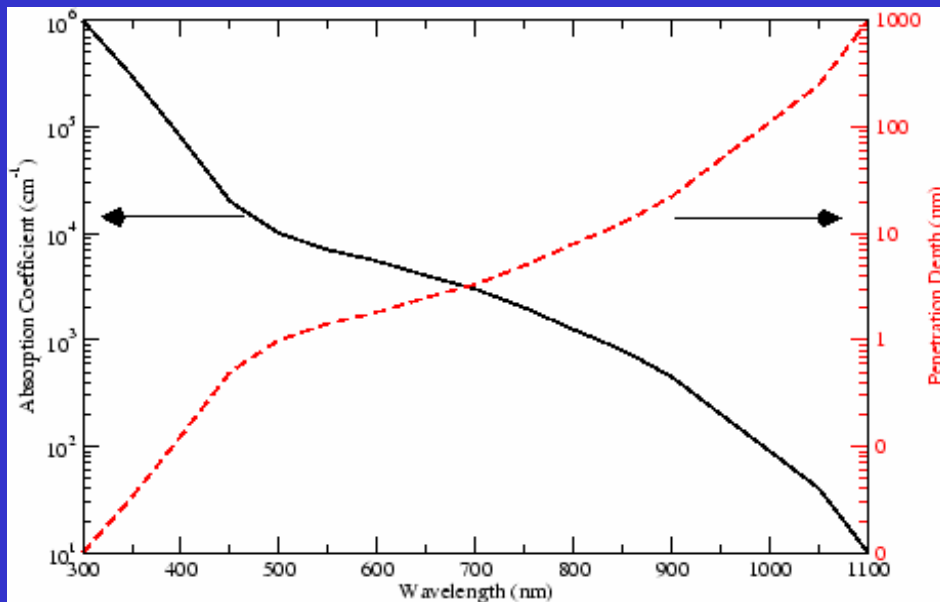
Only electrons trigger the avalanche

Both holes and electrons trigger the avalanche

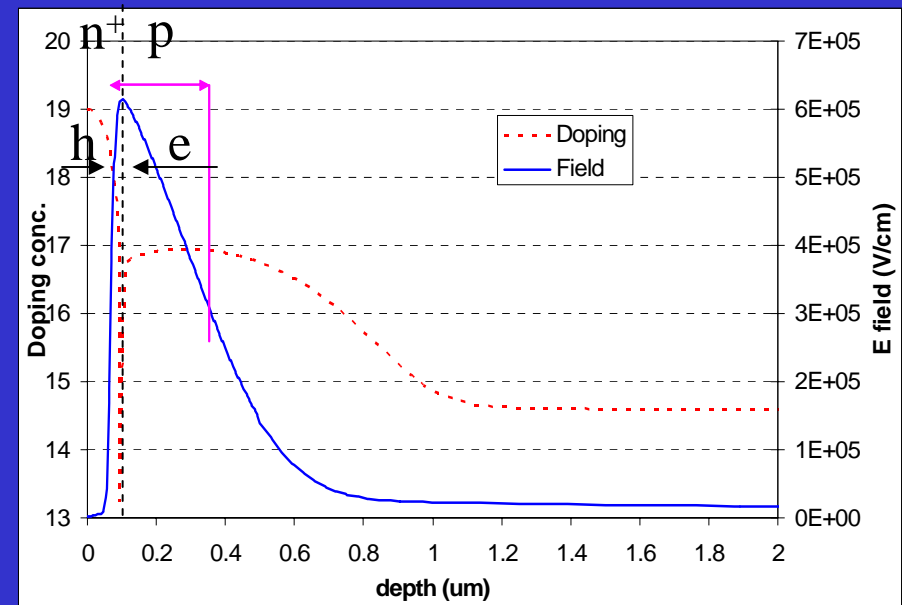
Only holes trigger the avalanche



# Light absorption



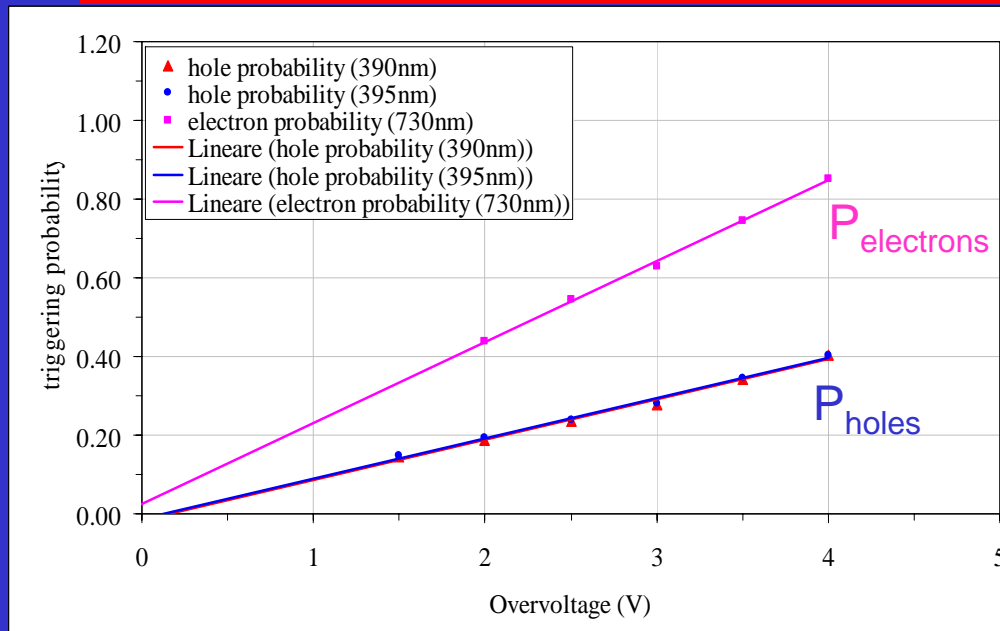
Attenuation of the light intensity in silicon (Beer-Lambert law)



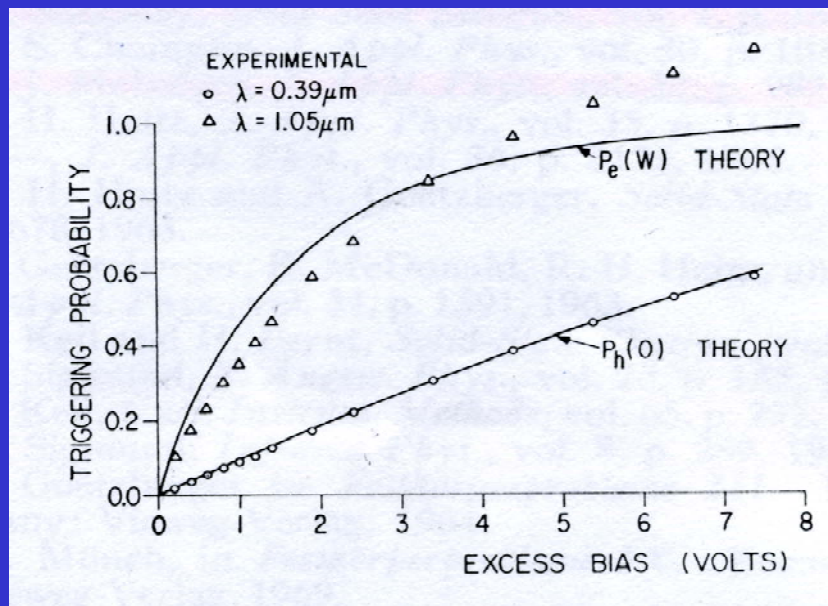
Simulated doping profile and electric field of the SiPM

- At low wavelengths only the holes cross the high field region & trigger the avalanche  
⇒ triggering probability @ low  $\lambda$  (e.g. 385, 390, 395nm) = hole triggering probability
- At high wavelengths only the electrons cross the high field region & trigger the avalanche  
⇒ triggering probability @ high  $\lambda$  (e.g. 700nm) = electron triggering probability

# Electron & hole triggering probability



- $P_e$  &  $P_h$  increase linearly with the overvoltage up to 4V
- The slight difference of 0V point could arise from the unavoidable statistical variation of the  $V_{\text{breakdown}}$  across the structure



- Ref. data: W. Oldham & all,
- “Triggering phenomena in avalanche diodes”, IEEE Trans. on Electron Devices Vol. ED-19, No.9, Sept. 1972

# Summary

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- Photon detection efficiency of the SiPM devices developed at ITC-irst
- Two experimental methods:
  - DC & pulses counting
  - very good agreement in between the two methods ( $\lambda=550\text{nm}$ )
- Photon detection efficiency:
  - Depends of three factors:
    - geometrical efficiency:  $\sim 15\text{-}30\%$  (e.g. function of the layout design)
    - quantum efficiency:  $> 95\%$  in the blue region (optimized for  $420\text{nm}$ )
    - triggering probability:  $P_e > P_h$
  - Maximum in the range  $500\text{-}600\text{ nm}$  :
    - $\sim 16\%$  @  $4\text{V}$  overvoltage for a device of  $\epsilon_{\text{geom}} = 22\%$
    - for low  $\lambda$  it is reduced by the  $P_{\text{triggering}}$  (only holes trigger the avalanche)
    - for high  $\lambda$  it is reduced by the QE (optimized for blue region)
  - Increases linearly with the overvoltage (at least up to  $4\text{V}$  overvoltage)